

Docket Number (optional)
02Micro 03.15

Application No.
10/624,295

INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

Applicants(s)
Spenea et al.

Filing Date
July 22, 2003

Group Art Unit
2816

AUG 16 2004

U.S. PATENT DOCUMENTS

*Examiner Initial	REF	DOCUMENT NUMBER	DATE	NAME	CLASS/SUBCLASS	FILING DATE IF APPROPRIATE
Kan		5,079,516	01/07/92	Russell et al.	330/261	
		6,338,032	01/08/02	Chen	703/16	
		6,472,897	10/29/02	Shyr et al.	324/765	
		6,410,398	6/25/2002	Forel et al	438/382	

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS/SUBCLASS	TRANSLATION	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Kan		S. Laville, S. Pontarollo, "Integrated Offset Trimming Technique", ST Microelectronics DSG, and D. Dufaza, D. Auvergne, LIRMM (date unknown).

EXAMINER

WELLS

DATE CONSIDERED

12/2/04

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include Copy of this form with next communication to applicant